L Number	Hits	Search Text	DB	Time stamp
2	50	Argon and ((ion adj mill) same etching)	USPAT	2003/02/27 09:49
3	0	L-shaped adj spacer and CH3F and O2 and	USPAT	2003/02/27 09:49
		anisotropically	1	1
4	0	L-shaped adj spacer and CH3F and O2	USPAT	2003/02/27 09:50
5	0	(L-shaped adj spacer) and CH3F and O2	USPAT	2003/02/27 09:50
6	8	(L-shaped adj spacer) and anisotropically	USPAT	2003/02/27 10:05
7	0	((L-shaped adj spacer) and	USPAT	2003/02/27 10:06
		anisotropically) and CH3F		!
8	1	((L-shaped adj spacer) and	USPAT	2003/02/27 10:13
		anisotropically) and chlorine		1
15	508	438/595.ccls.	USPAT	2003/02/27 10:19
16	0	438/595.ccls. and CH3F	USPAT	2003/02/27 10:19
17	67	438/595.ccls. and (fluorine or chlorine or	USPAT	2003/02/27 10:20
		02)		
18	15	438/595.ccls. and (fluorine or chlorine or	USPAT	2003/02/27 10:20
		O2).clm.		
19	8	(438/595.ccls. and (fluorine or chlorine	USPAT	2003/02/27 10:20
-		or O2).clm.) and spacer		
20	0	6391732.URPN.	USPAT	2003/02/27 10:23